

Form PTO-1449	Doctor Number (Optional)	Application Number
OPI INFORMATION DISCLOSURE CITATION IN AN APPLICATION.	TSMC-00-068BE	10/791,022
APR 15 2004 U.S. Patent and Trademark Office (use several sheets if necessary)	Applicant	Ta Lee Yu
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U. S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

OTHER DOCUMENTS (Including Author, Title, Date, Portion or Pages, Etc.)

~~pp.~~ - J.Chen et al., "Design and Layout of a High ESD Performance NPN Structure for Submicron Bipolar/Bipolar Circuits", IEEE Jnl. 1996, 0-7803-2753-5/96, pp. 227-232

EXAMINER

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